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Unique properties of silver and copper silica-based nanocomposites as antimicrobial agents

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The paper reports a new route for the fabrication and determination of physicochemical properties and biological activity, of metallic silica-based nanostructure (Ag/SiO₂, Cu/SiO₂). A research studies shows mono-dispersed nanoparticles in silica matrix with an average size of 12 nm for silver, as well as 12 nm and 4 nm, respectively for copper in hydrophobic and hydrophilic silica composites. The chemical analysis highlights metallic silver and copper ions heterogeneously distributed in the composite as well as metallic oxides such as Ag₂O, Cu₂O and CuO in hydrophobic system, and CuO in hydrophilic one. Structural research evidences the presence of amorphous, stoichiometric and non-stoichiometric crystalline phase of silica. Biological studies reveal potentially inhibition of growth gram-positive and gram-negative bacteria as well as microscopic fungi. The size of metal nanoparticles and level of silica hydrophobicity show the highest inhibition bacterial growth for hydrophilic system with embedding inside them, 4 nm in size copper nanoparticles. Finally, cytotoxic interaction against human cells with respect to silver and copper silica-based nanocomposites was not found.

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Introduction

Billions of microorganisms interact with human organism every day. Most microorganisms are symbiotic and helpful; however, 30% of them are pathogenic and are able to impact human health. Hence, new solutions for elimination of those pathogens are needed. One of the relatively new ideas for pathogens prevention is the fabrication of new materials, which could combine antibacterial or antifungal properties with long-acting times and neutral influence on the environment. One of the potential solution are metallic nanoparticles (NPs) especially silver, copper, zinc or gold.^{1–3} Their antimicrobial effect results from the cell membrane and DNA damages,⁴ interaction with enzymes from thiol groups⁵ or are associated with generating hydrogen peroxide.⁶ What is more, the biocidal properties of metallic NPs strongly depend on particle size,^{7,8} agglomeration^{9,10} or release rate of metal ions.^{11,12} It is believed that their impact on

natural environment compared to organic compounds is lower.^{13,14} Hence, metallic nanoparticles are applied to commonly used organic and inorganic products such as cosmetics, detergents, protective wood paints, dietary supplements or pesticides.^{15–18} The application of metallic NPs has certain limitations linked to the relative ease of leaching of metal ions into the environment. In addition, silver and TiO₂ nanoparticles are able to migrate from textile to water, and then with sewage enter into ecosystems.¹⁹ As a result, metals can easily accumulate in soil, uptake by plants and finally enter into food chain. What is more, there are not possible to completely separate the toxic effect of silver nanoparticles and silver ions. Das *et al.* have recently demonstrated that to prevent the formation of Ag⁺ ions and to reduce its toxicity, the necessary is to combine them with silica and proteins.²⁰ Other solutions are based on fabrication of nanocomposite coatings or by packing metallic nanoparticles in organic or inorganic matrix like polymer, ceramics or glasses.^{21–23} It turned out, that combination of water soluble polymer (PEG) and AgNPs of suitable sizes (<100 nm) prepared in form of coatings,^{24–27} or combination of metal nanoparticles with magnetite (Fe₃O₄) NPs improve antibacterial and biomedical properties.²⁸ However, the most versatile matrices seems to be composed of chemically modified silica. It was shown that the metal ions embedded into silica matrix have vast potential in a variety of applications; especially as a cytotoxic material for bacteria (silver-based system)²⁹ and fungi (copper-based system).²⁹ Copper–silica (Cu/SiO₂) nanosystem also revealed an excellent anti-corrosion properties, thermal stability and low

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conductivity values.³⁰ Moreover, such composites are characterized by slowly discharge of metallic ions from the silica matrix in a long period of time.²⁹ It is worth to mention, that in many cases the effectiveness of those nanocomposites depends strongly on their manufacturing techniques; like chemical reactions,^{31–35} sol-gel³⁶ or sputtering deposition.¹⁴

In this paper, we report a chemical synthesis of copper- and silver- silica dioxide nanocomposites (NCs) in the form of nanopowders. Physicochemical analysis including determination of particle shape, size and morphology, as well as phase identification were performed using X-ray diffraction (XRD), Scanning (SEM) and Transmission (TEM) Electron Microscopy. Molecular interactions between elements and distribution of individual elements in composites were identified in detail by infrared and Raman spectroscopies, energy dispersive X-ray (EDX) and X-ray photoelectron spectroscopy (XPS). Antimicrobial activity of the synthesized NCs against bacteria, yeast and fungi was tested. Finally, the control test of the cytotoxicity was performed on human fibroblast cells (NHDF line).

Nanocomposite synthesis

Silver and copper silica-based NCs were synthesized by chemical reaction method. The initial materials included two types of silica – hydrophobic (SiO_2^{h}) and hydrophilic (SiO_2^{f}), sodium hydroxide, nitric acid, ammonia, silver acetate and copper acetate. All commercially available chemicals were purchased in Avantor Company, Gliwice and were analytical grade (purity above 99.99%). However, the amorphous silica (Orisil 380 and M300) as a matrix for nanocomposite was manufactured by Orisil Ltd., Ukraine.

First stage of preparation route was focused on mixing the silicon dioxide with distilled water and sodium hydroxide. Next, water solution of silver acetate or copper acetate in ammonia, was added to the mixture providing to formation of colloidal suspension. In the last step, concentrated nitric acid was put into stirred colloid. The final product was filtered on

polyethylene filter, washed and dried at room temperature to obtain nanopowder. Hereby, three types of nanocomposites were obtained – Cu combined with hydrophobic and hydrophilic type of SiO_2 , and Ag combined with hydrophobic SiO_2 . Synthesis of Ag/SiO_2 with hydrophilic properties was unsuccessful, yet. The synthesis scheme is presented in Fig. 1.

Analytical methods

Physicochemical characterization

The crystallographic structure of Cu/SiO_2 and Ag/SiO_2 composites was studied by X-ray Powder Diffraction (XRD). The XRD data were recorded using Empyrean Panalytical equipment in the Bragg–Brentano geometry using $\text{Cu K}\alpha$ radiation ($\lambda = 1.54 \text{ \AA}$). The step-scan covered the angular range $20\text{--}110^\circ$ with the step of 0.02° . The phase analyzes for samples were made with use ICCD PDF-4 database.

The particle shape, size and morphology were in details investigated using Scanning (SEM) and Transmission (TEM) Electron Microscopy, whereas the surface chemical distribution of individual elements and ratio of components were studied, with energy dispersive X-ray (EDX) and X-ray Photoelectron Spectroscopy (XPS). SEM images were obtained by a FE-SEM 7600F Jeol instrument equipped with an Energy Dispersive X-ray mode (EDX) to visualize the elemental distribution of Ag or Cu, Si, O, C in analyzed area. TEM micrographs were collected with the use JEOL JEM 3010 microscope working at 300 kV equipped with $2k \times 2k$ Orius TM 833 SC200D Gatan CCD camera. The XPS measurements were taken with the use of Prevac & VGScienta spectrometer. Monochromatic $\text{Al K}\alpha$ radiation was used for collecting broad energy range survey spectra as well as spectra of particular core levels including Ag 3d, Cu 2p, O 1s and C 1s. The determination of chemical composition and oxidation states in both Ag/SiO_2 and Cu/SiO_2 systems was included. The spectra were shifted with respect to carbon C 1s line at 284.6 eV and corrected for the background signal using the integrated Shirley algorithm. The bands were fitted by

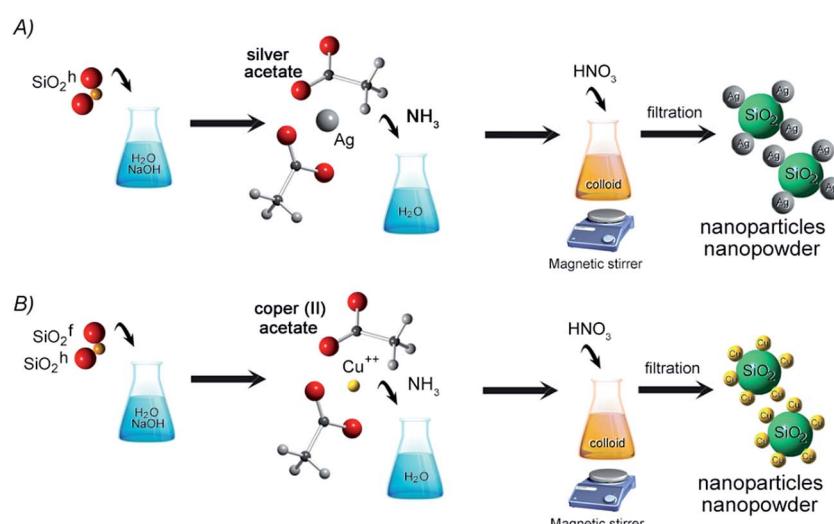


Fig. 1 The synthesis scheme of (A) silver-silica and (B) copper-silica nanocomposites.



a composition of Gaussian and Lorentzian lines using MultiPak software.

The optical investigation using Infrared (FTIR) and Raman Spectroscopy (RS) were carried out to analyze the material structure as well as the type of molecular interaction between elements in composites. FTIR measurements were carried out using an Agilent Cary 640 FTIR spectrometer equipped with a standard source and a DTGS Peltier-cooled detector. The spectra have been collected using GladiATR diamond accessory in the 450–4000 cm⁻¹ range. All spectra were accumulated with a spectral resolution of 4 cm⁻¹ and recorded by accumulating of 16 scans.

RS investigations were realized using a WITec confocal CRM alpha 300 Raman microscope. The spectrometer was equipped with an air cooled solid state laser operating at 532 nm. A dry Olympus MPLAN 100 × /0.9 NA objective was used. The integration times of 20 s per spectrum at resolution of 3 cm⁻¹ were applied. The monochromator of the spectrometer was calibrated using Raman scattering line produced by a silicon plate (520.7 cm⁻¹). Finally, the infrared and Raman data were analyzed by baseline correction and using Voigt peak fittings procedure in Grams Software Package.

Antimicrobial properties of nanocomposites

Spot test. Toxicity of the nanomaterials was examined against 9 different microorganisms: three laboratory strains of bacteria: *Escherichia coli* (DSM 1103), *Pseudomonas putida* G7 (DSM 4476), *Arthrobacter globiformis* (PCM 2134); three yeast strains: *Saccharomyces cerevisiae* (DSM 70449), *Candida tropicalis* (DSM 11953), *Candida albicans* (DSM 1386), and three filamentous fungi: *Aspergillus niger* Van Tieghem (DSM 1957), *Aspergillus terreus* Thom (DSM 1958), *Scopulariopsis brevicaulis* (Saccardo) Bainier (DSM 9122).

The 'spot test' was performed as described in the references³⁷ with minor modifications. Briefly, bacterial and yeast cells were cultivated 24 hours in LB and YPD, respectively, at 28 °C, 160 rpm. Cells suspension was diluted (1 : 50 and 1 : 40 for laboratory bacteria and yeast, respectively) in fresh growth medium and further cultivated (28 °C, 160 rpm) for 4–6 hours until mid-exponential growth phase at OD_{600 nm} values 0.6 for bacteria and 0.8–1.0 for yeast. The cells were harvested by centrifugation at 4700 rpm for 10 min at 20 °C in 50 mL polypropylene falcon, the pellet was suspended in sterile demineralized (DI) water (Milli-Q, Millipore) and centrifuged again. Finally, the cells were re-suspended in DI water to a density of ~10⁷ CFU mL⁻¹ for bacteria (OD_{600 nm} 0.1) and yeast (OD_{600 nm} 1.2) as described by Suppi *et al.*³⁷ Filamentous fungi were maintained in test tubes containing Czapek-Dox medium. Cultures were incubated at 30 °C and humidity up to 90% for 2 weeks. 5 mL of sterile 0.2% SDS solution were poured into test tubes in order to reduce hydrophobicity of fungal spores. After vigorous mixing, the spores were separated from the hyphae by filtration of suspension through sterile cotton wool and centrifugation at 4000 rpm. Spores were then re-suspended in sterile DI. After triple washing with water and centrifugation the

spore suspension concentration was adjusted to 10⁶ spores per mL.

Afterwards, 100 µL of cell suspension in DI water was added to 100 µL samples of nanomaterials Ag/SiO₂^h, Cu/SiO₂^h, Cu/SiO₂^f. As a reference, ion forms of Ag and Cu (AgNO₃ and CuSO₄, respectively) were used. All chemicals were tested in six nominal concentrations: 0.01, 0.1, 1.0, 10, 100 and 1000 mg L⁻¹. The stock solutions (2000 mg L⁻¹) of Ag/SiO₂^h, Cu/SiO₂^h, Cu/SiO₂^f, AgNO₃ and CuSO₄ were prepared freshly in sterile DI water and homogenized using ultrasonic probe (PolSonic 3) at 2 × 160 W for 1 h just before test. The stocks were diluted in DI water and tested concentrations were incorporated onto 96-well microplates (BD Falcon). Test organisms were exposed to chemicals in DI water at 24 °C for 24 h without shaking in the dark. Each experiment was repeated three times.

After 24 hour exposure, 5 µL of the cell suspension was pipetted as a 'spot' onto LB or YPD agar plates which were incubated for 24 h (bacteria) or 72 h (yeast) at 28 °C. Formation of a visible 'spot' (colonies) was used for determination of the ability of test organisms to grow on agar medium. Minimum biocidal concentration (MBC) of the NCs and ion forms of silver and cooper was determined as the lowest tested concentration which completely inhibited the formation of visible colonies after subculturing on toxicant-free agar media.

Inhibitory concentration IC₅₀

Inhibitory concentration IC₅₀ of nanomaterials was assessed for bacterial strains: *Escherichia coli* (DSM 1103), *Pseudomonas putida* G7 (DSM 4476), *Arthrobacter globiformis* (PCM 2134). For this purpose, slightly modified method described by Suppi *et al.*³⁸ was used. Bacteria culture from mid-exponential growth phase, obtained as described for 'spot test', were diluted with fresh LB medium to OD_{600 nm} 0.1. Subsequently, 50 µL of cell suspension was added onto 96-well microplates to 50 µL of six double concentrated solutions of tested compounds prepared in DI water as in 'spot test'. Thereby, the nominal concentrations (0.01, 0.1, 1, 10, 100, 1000 mg L⁻¹) of Ag/SiO₂^h, Cu/SiO₂^h, Cu/SiO₂^f, AgNO₃ and CuSO₄ was obtained in rows A–F. As a control, into the row G 50 µL of DI water without any compound was inoculated by 50 µL of cell suspension in LB. Microplates were incubated at 28 °C without shaking in the dark. Each concentration of the tested chemicals and control culture for each bacterial strain was studied in triplicate. Value of the nanomaterial concentration that makes 50% inhibition of the bacterial growth with relation to the control was calculated after 24 h incubation in half-strength LB medium. Such value was based on the curve of inhibition and expressed as means standard deviation (SD).

Toxicity of nanocomposites – cell culture and cytotoxicity assay

Human fibroblast (NHDF) cells originated from the American Type Culture Collection were the subject of the toxicity test. Cells were grown as monolayer cultures in 75 cm² flasks (Nunc) in Dulbecco's Modified Eagle Medium (DMEM). The medium was supplemented with 15% fetal bovine serum (Gibco) and



100 mg L⁻¹ of gentamycin (Gibco). The cell lines were maintained at 37 °C in a 5% CO₂ incubator and passaged every 3–4 days as required. Exponentially growing cells were harvested through the trypsinization of sub-confluent cultures. Cells were seeded into 96-well cell culture microtiter plates (Nunc) at concentrations of 4.0 × 10³ cells per well and cultured for 24 h. After this time, the growth medium was exchanged for a medium containing the growing concentrations of the tested compounds. Stock solutions of the compounds being investigated were prepared in sterile DMSO. The highest possible concentration of stock solutions of the tested compounds (in depending on solubility) were prepared in sterile DMSO. The final concentration of DMSO used in the culture medium did not exceed 0.2% and had no effect on cell growth. After 72 h of incubation, with the compounds being investigated, under standard cell culture conditions, the medium was replaced with 100 µL of DMEM without phenol red. The metabolic activity of viable cells was determined by adding 20 µL of CellTiter 96AQueousOne Solutions – MTS (Promega) to each well followed by 1 h incubation. The MTS assay is a colorimetric method for determining the number of viable cells. A standard solution containing 100 µL of DMEM without phenol red and 20 µL of MTS solution was used to determine 'blank' absorbance. The absorbance was measured at 490 nm using a SynergyTM4 microplate reader (BioTek).

Inhibitory concentration (IC₅₀) was also defined for human cells as the compound concentration that was necessary to reduce the proliferation of cells to 50% of the untreated control cells and expressed as means ± standard deviation (SD) in GraphPad Prism 5 software. Each individual compound was tested in triplicate.

Cell imaging

For cell morphology analysis, NHDF cells were seeded in 3 cm Petri dishes (Nunc) and incubated at 37 °C for 24 h. Then, the medium was removed and freshly prepared solutions of tested compounds: Ag/SiO₂^h (100 mg L⁻¹); Cu/SiO₂^f (50 mg L⁻¹); Cu/SiO₂^h (40 mg L⁻¹) were added. After 72 h, the solution of tested compounds was removed and the cells were washed with Phosphate Buffered Saline (PBS) and maintained in DMEM without phenol red. The observation was performed under an inverted Zeiss epifluorescence microscope, Axio Observer Z1 (Carl Zeiss, Germany) in bright field.

Results

Physicochemical characterization

X-ray diffraction. The XRD data were collected for silver/and copper/silicon dioxide nanocomposite (Fig. 2). The SiO₂ was identified in all samples; amorphous and three silica dioxide phases were detected depend on the matrix. For the Ag/SiO₂^h nanocomposite a monoclinic (C2/c) phase of SiO₂ (01-075-4407) with cell parameters $a = 6.986 \text{ \AA}$, $b = 12.231 \text{ \AA}$, $c = 7.110 \text{ \AA}$ and $\beta = 120.746^\circ$ and a cubic ($F\bar{m}\bar{3}m$) phase of Ag (04-004-8730) with cell parameters $a = 4.085 \text{ \AA}$ were identified. However, the dominant phase originated from the main component of the

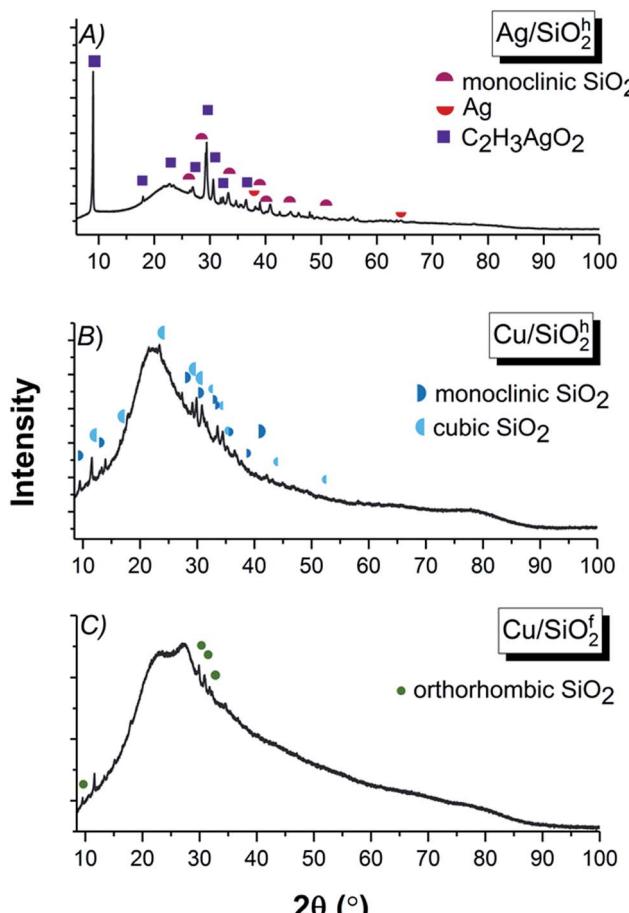


Fig. 2 XRD results for (A) Ag/SiO₂^h, (B) Cu/SiO₂^h and (C) Cu/SiO₂^f.

synthesis, constitutes the silver acetate (00-057-0335) with $a = 6.112 \text{ \AA}$, $b = 5.594 \text{ \AA}$, $c = 19.763 \text{ \AA}$ cell parameters and orthorhombic ($C222_1$) space group (Fig. 2A). Due to strong impact of the silicon dioxide the peaks linked to copper on the XRD spectra are difficult to separate with silica. Therefore, in the hydrophobic (SiO_2^h) sample, two silicon dioxide phases (Fig. 2B) were designated as: monoclinic (01-089-1667) ($P\bar{2}1m$) with unit cell parameters of $a = 9.680 \text{ \AA}$, $b = 19.580 \text{ \AA}$, $c = 7.400 \text{ \AA}$ and $\beta = 81.10^\circ$ and cubic (01-075-3901) ($Pm\bar{3}n$) with $a = 10.730 \text{ \AA}$. The hydrophilic (SiO_2^f) silicon dioxide system was characterized by the orthorhombic (01-079-0563) ($Im\bar{mm}$) space group with unit cell parameters of $a = 18.557 \text{ \AA}$, $b = 13.889 \text{ \AA}$ and $c = 7.249 \text{ \AA}$ (Fig. 2C).³⁹

Transmission and scanning electron microscopy. To shed more light on the nanostructure of silica based composites, the TEM investigation was performed. The obtained results showed heterogenic distribution of spherical-like Ag and Cu nanoparticles dispersed in the silicon dioxide matrix (Fig. 3A–F). Diffraction patterns related to silver showed presence of metallic phase with cell parameters $a = 4.086(1) \text{ \AA}$ while the average size of nanoparticles dispersed in the matrix estimated as 12.55(4) nm. In turn, TEM data supplied XRD outcomes illustrating the presence of copper crystalline structure in hydrophobic and hydrophilic silicon matrix, with $F\bar{m}\bar{3}m$ space



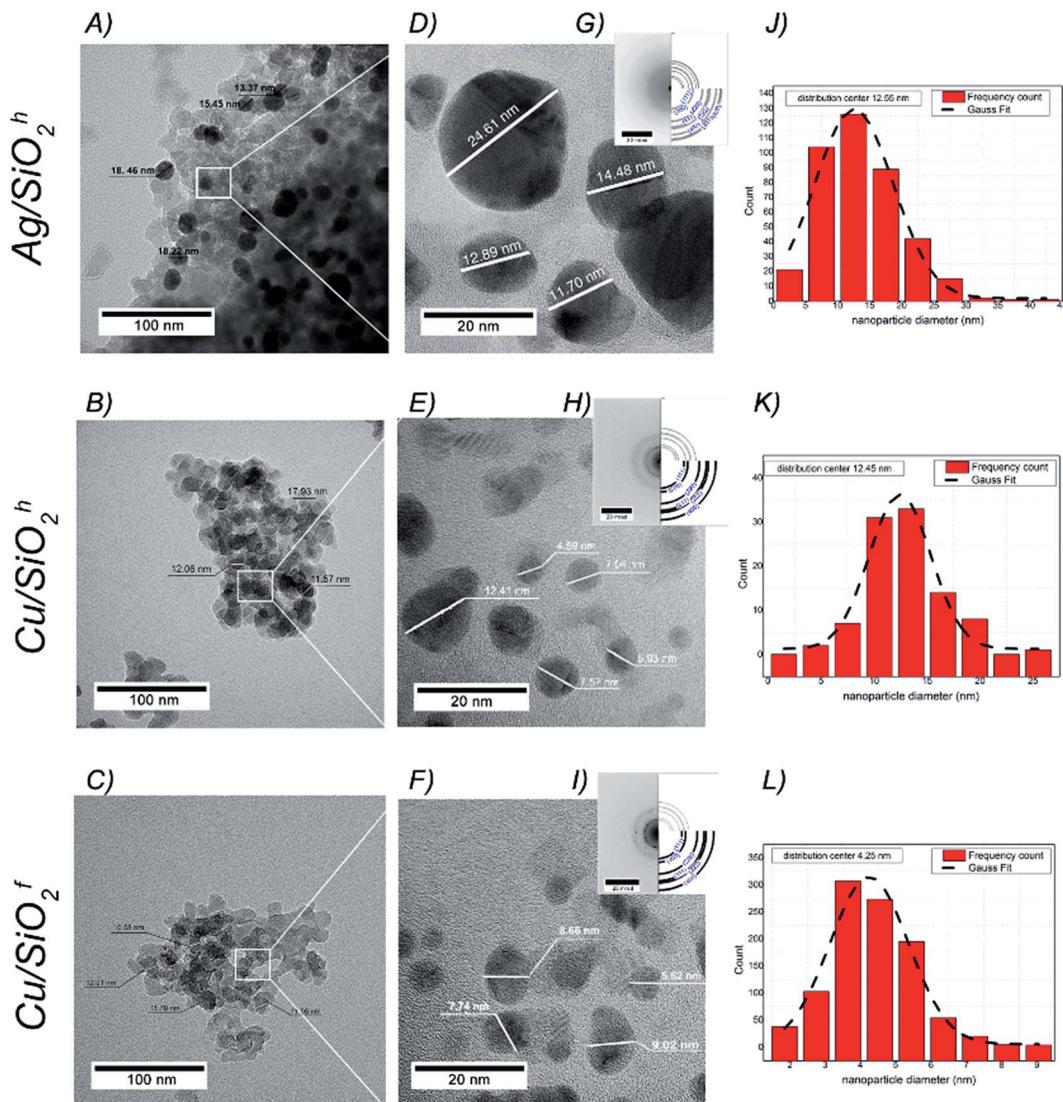


Fig. 3 (A)–(C) TEM micrographs with the scale bar of 100 nm and (D)–(F) with the scale bar of 20 nm obtained for Ag/SiO_2^h , CuSiO_2^h and Cu/SiO_2^f nanocomposites. The brightest objects mean silica matrix, whereas the dark ones are silver or copper particles embedded into the silica matrix. (G)–(I) Insets show SAED patterns for each nanocomposite (left site) with theoretical fitting (right site) while (J)–(L) the particle size distribution for each system was based on three different TEM images.

group and cell parameters $a = 3.615(1)$ Å (SEAD patterns in Fig. 3G–I). The diameter of copper particles in hydrophobic matrix determined with an accuracy to 12.45(5) nm. It turns that the smallest copper nanoparticles identified in hydrophilic copper system with the average size equal to 4.25(8) nm (Fig. 3J–L). The morphology of all samples was also investigated by SEM technique. Here, the NPs in silicon dioxide systems formed structures of varying degrees of agglomeration (Fig. 4A–C), with more less homogeneous distribution of Ag, Cu, Si and O in the whole volume of NC material (Fig. 4D–O). The atomic concentration from the EDX indicated the highest concentration of Cu in hydrophilic matrix. The analysis also showed the number of carbon atoms, which may result from residues of polymer or basic substance used during synthesis process (see Table 1).

X-ray photoemission spectroscopy. The result obtained from the XPS, surface sensitive technique sensing about 4 nm thick

surface layer, showed that dominant component of the NCs is SiO_2 . Additionally, the concentration of carbon is lower on the surface, as compared to deeper parts of sample obtained from EDX data. Moreover, lower concentrations of Ag and Cu were detected with relation to EDX which gave values of: 95.89% (Ag/SiO_2^h), 77.42% (Cu/SiO_2^h) and 91.16% (Cu/SiO_2^f). The more detailed XPS spectral analysis of chemical state of Ag, Cu, Si, O and C is shown in Fig. 5. All fitted components of Ag 3d, Cu 2p, Si 2p, O 1s and C 1s core levels have been collected in Table 2.

The analysis of Ag 3d_{5/2} core level (Fig. 5A) in case of Ag/SiO_2^h system indicates presence of silver in two different chemical states. The binding energy of 368.50 eV is related to pure metallic silver.⁴⁰ However, the same binding energy might be assigned to silver ions in silver acetate. Second component with binding energy equal 366.35 eV can be attributed to surface Ag formed in the O/C–O environment.⁴¹ In case of chemical states



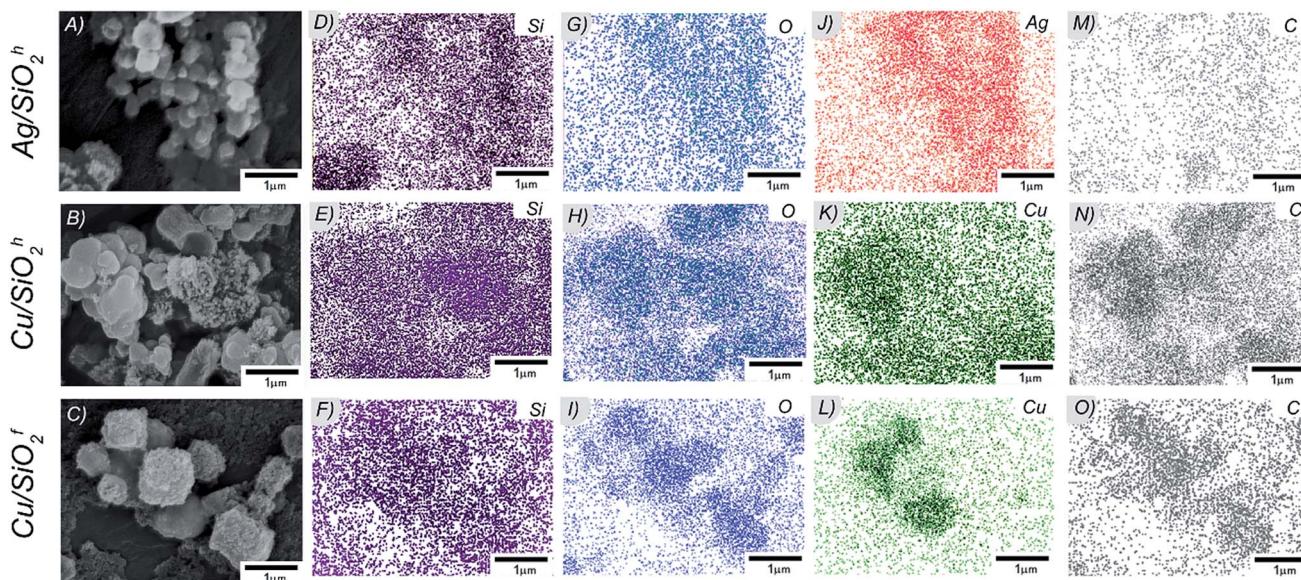


Fig. 4 (A–C) The morphology of the nanocomposites obtained by SEM as well as (D–O) an individual distribution of Si (violet), O (dark blue), Ag (red), Cu (green) and C (grey) based on the EDX images obtained for Ag/SiO_2^h , Cu/SiO_2^h and Cu/SiO_2^f nanocomposites.

Table 1 Comparison of the atomic concentration resulted from EDX and XPS for Ag/SiO_2 and Cu/SiO_2 nanocomposites

Atomic concentration [at%]	EDX			XPS		
	Ag/SiO_2^h	Cu/SiO_2^h	Cu/SiO_2^f	Ag/SiO_2^h	Cu/SiO_2^h	Cu/SiO_2^f
Ag	3.41	—	—	0.14	—	—
Cu	—	2.48	11.77	—	0.56	1.04
Si	4.64	3.22	1.72	32.96	22.62	18.90
O	50.61	45.89	31.81	63.87	52.15	51.84
C	41.34	48.41	54.70	3.03	24.67	28.22

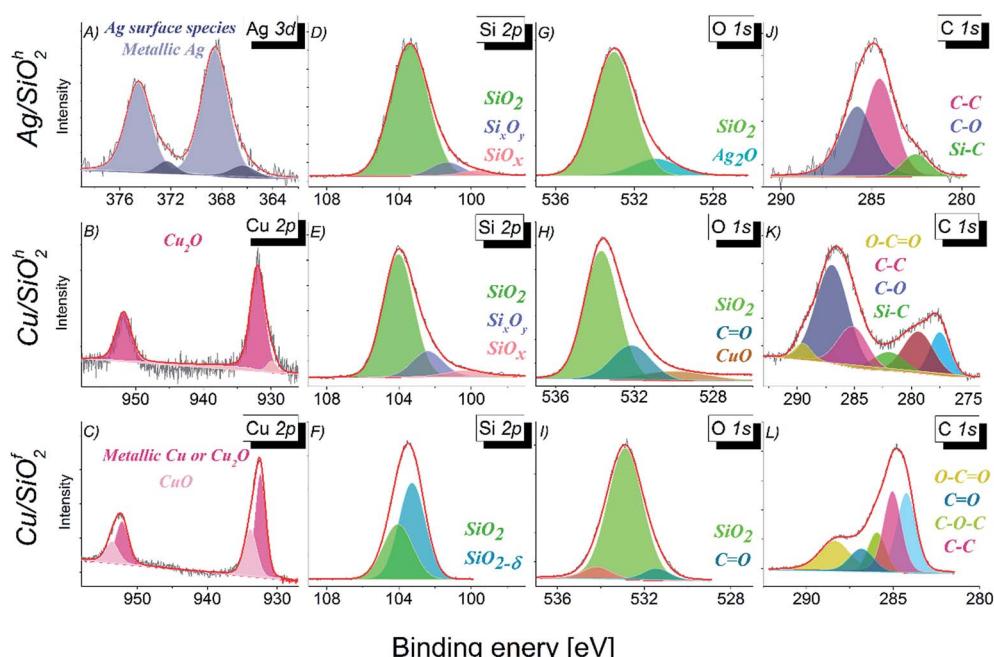


Fig. 5 The XPS spectra with the result of a fitting (A) Ag 3d, (B–C) Cu 2p, (D–F) Si 2p, (G–I) O 1s and (J–L) C 1s.



Table 2 Binding energies of Ag 3d_{5/2}, Cu 2p_{3/2}, Si 2p, O 1s and C 1s core levels resolved for Ag/SiO₂ and Cu/SiO₂ systems

System	Binding energy [eV]				
	Ag 3d _{5/2}	Cu 2p _{1/2}	Si 2p	O 1s	C 1s
Ag/SiO ₂ ^h	366.35	—	99.7	530.9	282.6
	368.5	—	101.35	533.0	284.55
Cu/SiO ₂ ^h	—	929.9	100.4	530.0	277.5
	—	932.0	102.4	532.2	285.15
Cu/SiO ₂ ^f	—	932.5	104.0	533.7	286.9
	—	932.5	103.3	531.4	289.5
Cu/SiO ₂ ^f	—	933.9	104.1	534.2	285.9
	—	—	—	—	288.4

of copper in Cu/SiO₂ systems, two different chemical states were observed (Fig. 5B and C). High binding energy state located at 932.0 eV indicates the presence of Cu₂O oxide in the Cu/SiO₂^h sample.⁴² In case of Cu/SiO₂^f the peak at the 932.5 eV can be assigned to pure metallic state of cooper or Cu₂O because the binding energies of both chemical states are very close to each other.⁴³ The dominant chemical state of copper in Cu/SiO₂^f sample, in contrast to the one observed in Cu/SiO₂^h, is CuO (Table 2). The presence of SiO₂ compound, as mentioned above has been confirmed for Ag/SiO₂ and Cu/SiO₂ systems (Fig. 5D–F).^{40,44} The analysis of Si 2p line indicated presence of the non-stoichiometric SiO_x oxides.⁴⁴ The other phase of SiO₂ has been detected in Cu/SiO₂^f where the atypical non-stoichiometric SiO_{2–δ} oxide constitutes the dominant component, while the stoichiometric SiO₂ has a smaller contribution to the Si 2p core line. The shape analysis of the O 1s core level (Fig. 5G–I) has confirmed the dominant character of SiO₂ compound in all systems.

Additionally, the oxygen states indicate presence of Ag₂O oxide (530.9 eV),⁴⁰ CuO oxide (530.0 eV), as well as chemical states which can be related to bonding between carbon and oxygen. The one at lower binding energy is originating from the double C=O bonding (Cu/SiO₂^h), whereas the one of the higher binding energy in case of Cu/SiO₂^f to the polymer like bonding. Finally, the photoemission spectra of C 1s core level has revealed the typical organic components like C–O, C–C and C=O bonds.^{40,45–47} This can be a consequence of the presence of residues remaining in the samples after the synthesis process or environment adsorbents containing carbon (Fig. 5J–L).

FTIR analysis. To resolve the problem of FTIR spectra interpretation of NCs, reference spectra of the pure SiO₂, Ag and Cu were presented (Fig. 6A–C). The results showed, that the SiO₂ spectrum is dominated by three characteristic absorption bands at 450–1500 cm^{–1}, which originate from Si–O–Si vibrations.^{1,48,49} The band at 952 cm^{–1} is ascribed to the Si–OH bond,^{1,49,50} while the rest of the them stems from structural deformation within silica network and from non-stoichiometric silicon oxide.⁵¹ The pure Ag sample showed characteristic bands

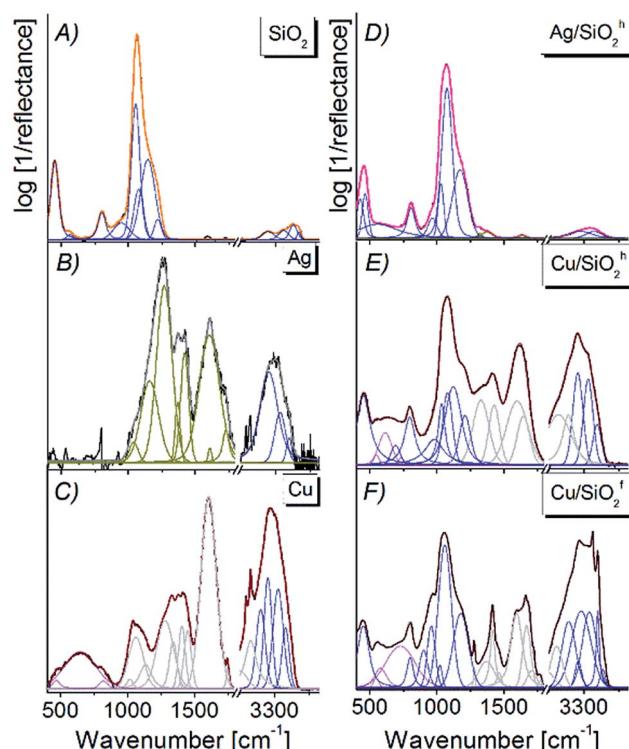


Fig. 6 FTIR spectra of (A) pure silica, (B) Ag, (C) Cu, (D) Ag/SiO₂^h, (E) Cu/SiO₂^h, (F) Cu/SiO₂^f nanocomposites spectra fitted by Voigt function in the 450–4000 cm^{–1} range.

in the 1100–1800 cm^{–1} range (Fig. 6B) arise from silver nanoparticles as well as bands of the hydroxyl groups in form of the shell layer around the them in the 3200–3800 cm^{–1} range. FTIR data for Cu sample revealed presence of bands resulting mainly from CH₂ and OH modes due to the presence of organic carbon as well as bands centered in the 600–700 cm^{–1} range corresponding to the Cu–O stretching vibration¹ (Fig. 6D).

Analyzing the Ag/SiO₂^h spectrum, one can find the slight redshift about 10 cm^{–1} and broadening of main silica band, due to formation of the Si–O–Ag bond.⁴⁸ At the same time, the splitting of Si–O–Si band centered originally at 445 cm^{–1} on two bands centered at 429 cm^{–1} and 465 cm^{–1} points to the deformation of silica network as well as formation of the outer polymeric cage within silica network (Fig. 6C).^{48,52} Further analysis showed weak intense bands observed on silver–silica infrared spectra located in the 1650–1750 cm^{–1} range. This band corresponds to the stretching vibration of C=O bond from the aldehyde group, while bands located in the 3200–3800 cm^{–1} range can be associated with stretching mode of ν(Si–OH), ν(OH) as well as molecular water adsorbed on the silica surface.^{1,49,53} Interestingly, an increase in the 3200–3800 cm^{–1} bands result from an increase amount of hydroxyl groups due to their localization over the AgNPs and effectively embedded silver nanoparticles inside the SiO₂ frame. At the same time, a modification in band intensity results from an increase in the number of an intermolecular H-bonding interaction are associated with a hydrogen bond scheme realized by the combination of Si–O–Si framework and hydroxide from AgNPs modifier.



The Cu/SiO₂ spectrum is dominated by polymer-like bands (1300–3800 cm⁻¹), partially overlapping with silica and organic carbon (400–1300 cm⁻¹) ones. The deconvolution procedure and peak fitting analysis revealed presence of Cu–O (600–700 cm⁻¹), Si–O–Si (450–1500 cm⁻¹) and Si–OH (950 cm⁻¹, 3000 cm⁻¹) vibrations. The bands located at 600–1250 cm⁻¹ might be assigned to the deformation of δ (Cu–O–Si) bonds located at the interface between CuO and SiO₂.¹ In addition, sharper bands observed in the hydroxyl region of Cu/SiO₂^f suggest higher contribution of hydroxide than for hydrophobic composite (Fig. 6E and F). High band intensities in this range also determine the formation of hydrogen bonding of copper nanoparticles with silica matrix.

Raman analysis. Further, more local analysis with respect to FTIR data have been performed using Raman spectroscopy (RS). The reference RS data for pure SiO₂ system is presented in Fig. 7A (reference spectra of pure Ag and Cu NPs) were previously reported by Nowak *et al.*³³ The data for pure silica showed presence of peaks assigned to: the rotational modes of the silica structural units (235, 308 cm⁻¹) and vibrational active modes within silica skeleton to bands at 391 cm⁻¹ (ω_1), 478 cm⁻¹ (D1), 606 cm⁻¹ (D2), 804 cm⁻¹ (ω_3) and 1055 cm⁻¹ (ω_4) (see Fig. 7A

and Table 4).^{54–62} The position of band at 391 cm⁻¹ depends strongly on the particle size of silicon oxide *i.e.* the smaller the particle, the higher wavenumber of the band.⁶³ Two Raman bands, labeled D1 and D2, arise from the three-member and four-member silicon–oxygen (*i.e.* siloxane) ring structures.⁶⁴ Raman bands located at about 1000 cm⁻¹ corresponds to silicon–oxygen stretching modes of SiO₄ group with four, three, two or one non-bridging oxygen in siloxane ring.⁶⁰ The other bands can be attributed to the structural deformation of silica network as well as the presence of hydroxyl groups attached to the silica skeleton.

Physicochemical properties of nanocomposites are strongly influenced by the concentration of metal embedded into the matrix. Thus, adding network modifiers, such as silver, copper or carbon, substantially changes the initial silica structure generating additional bands as well as changing intensity of other ones.⁵⁴ Looking more closely on the Ag/SiO₂^h spectrum (Fig. 7B) one can observe few low wavenumber bands ascribed to Si–(O–Ag) modes.^{65,66} The differences at ω_1 , D2 band positions are probably due to deformation of silica network, while the red-shift of D1 band for about 20 cm⁻¹ with respect to pure silica, arise from elongation of Si–O bond within three-fold ring silica structure. Above the 700 cm⁻¹ range, the Raman bands are generally assigned to –Si–O* structural elements which are characteristic for crystalline silica phase.^{54,64,67} Interestingly, an increase of Ag content gradually amplifies the band intensity at 235 cm⁻¹, which originates from Si–(O–Ag) mode (Fig. 7B and C) and the blue or red-shift band. This is an effect of silver interaction with silicon oxide network *e.g.* red-shift bands assigned to –Si–O* structural elements suggest elongation of Si–O bond.^{54,64,67} Finally, no bands associated with hydroxyl groups have been detected (Fig. 7B–D). On the other hand, Raman spectra of Cu/SiO₂ systems strongly depend on the type of silica type (Fig. 7E and F). For hydrophobic Cu/SiO₂^h system a small shift (few cm⁻¹) with respect to pure silica is an effect of relatively small interaction of copper on amorphous silica network,^{54,68} while the existence of additional lines indicates a copper–oxide bond (see Table 3). Moreover, two bands located at 262, 626 cm⁻¹ can be assigned to (Cu–O)–Si mode.^{69,70} Further, bands at 563, 673 cm⁻¹ can be assigned to (Cu₂–O)–Si vibration,⁷¹ while bands at 701, 781 cm⁻¹ suggest structural deformation of silica network. Interestingly, high intensity of line at 1093 cm⁻¹ suggest statistically high amount of –Si–O* structural groups coming from crystalline silica. In addition, weak band found between 3200–2800 cm⁻¹ indicates presence of organic moieties (C–H) confirmed by the SEM and XPS data. In case of hydrophilic Cu/SiO₂^f system, amorphous silica-bands are shifted ± 10 cm⁻¹ due to strong copper interaction with SiO₂ activating the (Si–O)–Cu vibration.⁷² Similar to hydrophobic system, two bands at 1031, 854 cm⁻¹ are an evidence of the –Si–O* structural elements originating from the crystalline silica.^{54,64} The intensities of all bands are closely related to those from pure silica suggesting only a weak interaction of copper with silica network. The increase of copper content in both samples lead to overlapping of bands arising from copper oxide and silica vibration. In that way, Raman spectrum of highly content copper–silica spectrum is dominated by bands at 277,

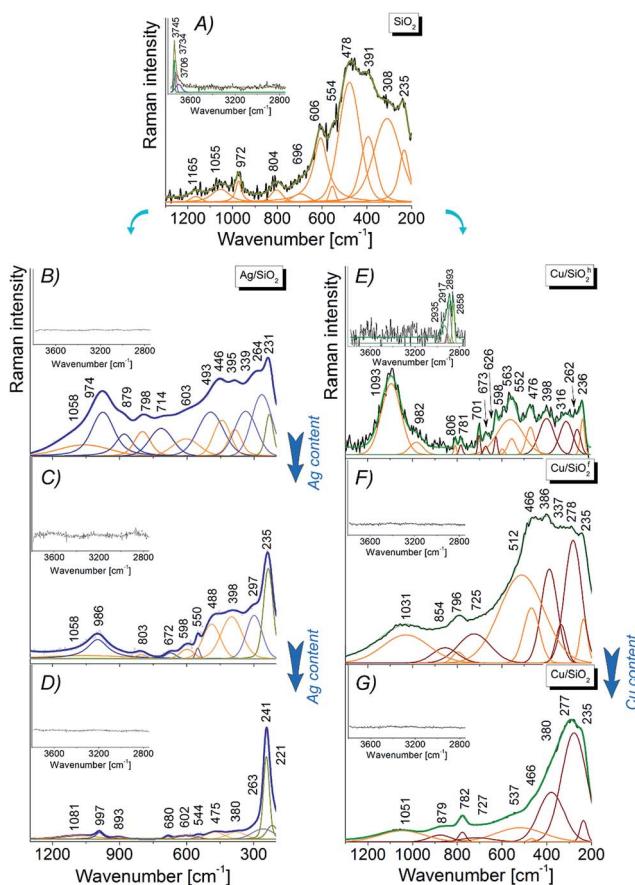


Fig. 7 Raman spectra of (A) pure silica, (B–D) silver–silicon oxide depends on the Ag content as well as (E) Cu/SiO₂^h, (F) Cu/SiO₂^f and (G) copper–rich silica with the Voigt peak fitted curves in the 1250–200 cm⁻¹ range. The insets showed magnified hydroxyl stretching region between 3800–2800 cm⁻¹.



Table 3 The Raman bands assignment for pure SiO_2 , Ag/SiO_2 and Cu/SiO_2 nanosystems

SiO_2	$\text{Ag}/\text{SiO}_2^{\text{h}}$		$\text{Cu}/\text{SiO}_2^{\text{h}}$		$\text{Cu}/\text{SiO}_2^{\text{f}}$		
Wavenumber [cm^{-1}]	Band assignment	Wavenumber [cm^{-1}]	Band assignment	Wavenumber [cm^{-1}]	Band assignment	Wavenumber [cm^{-1}]	Band assignment
235	Si–O	231	Ag–O ⁵	236	Si–O	235	Si–O
		264	(Ag–O)–Si	262	(Cu–O)–Si ^{70,73}	262	(Cu–O)–Si ^{70,73}
308, 391	Si–O(–Cu)	339, 395	Si–O(–Ag)	316, 398	Si–O(–Cu)	337, 386	Si–O(–Cu)
478	Si–O–Si bending (ω_1) ^{55–58,60–62}	446	Si–O–Si bending (ω_1) ^{57,58,60}	476	Si–O–Si bending (ω_1) ^{55–58,60,61}	466	Si–O–Si bending (ω_1) ^{55–58,60–62}
	Si–O(–Cu)				Si–O(–Cu)		Si–O(–Cu)
554	Si–O–Si bending (D1 defect), ^{55,56,58,68}	493	Si–O–Si bending (D1 defect) ^{60,61}	552	Si–O–Si bending (D1 defect)	512	Si–O–Si bending (D1 defect) ^{55,68}
606	Si–O–Si bending (D2 defect) ^{56,58,68}	603	Si–O–Si bending (D2 defect) ^{55,56}	598	Si–O–Si bending (D2 defect), Si–O(–Cu)		
				626	(Cu ₂ –O)–Si modes ⁷¹		
				673	(Cu ₂ –O)–Si modes ⁷¹		
696	Overtone (2B _{1g} type of symmetry)	714	Overtone (2B _{1g} type of symmetry)	701, 781	Overtone (2B _{1g} type of symmetry)	725	Overtone (2B _{1g} type of symmetry)
804	Si–O–Si symmetric stretching mode (ω_3)	798	Si–O–Si symmetric stretching mode (ω_3) ^{55,56}	806	Si–O–Si symmetric stretching mode (ω_3) ^{55,56,60,62}	796	Si–O–Si symmetric stretching mode (ω_3) ^{55,56,58,60,68}
972	SiO_4 (ref. 62)	879, 974	Si–O ⁶² Si–OH ^{54,64}	982	Si–O ⁶² Si–OH ^{54,64}	854	SiO_4 (ref. 62)
1055, 1165	Si–O ⁶²	1058	Si–O–Si antisymmetric stretching mode (ω_4) ⁵⁵	1093	Si–O–Si antisymmetric stretching mode (ω_4), Si–O	1031	Si–O ⁶²

Table 4 Minimum biocidal concentration (MBC) of tested on bacteria, yeast and microscopic fungi nanocomposites after 24 h exposure in deionized water at 24 °C in nominal concentrations from 0.01 up to 1000 mg L⁻¹. The results of tests of NCs have been combined with tests on AgNO_3 and CuSO_4 . All experiments were done in three replicates and average data from summarized. Different colors indicated different MBC values

Strain		$\text{Ag}/\text{SiO}_2^{\text{h}}$	$\text{Cu}/\text{SiO}_2^{\text{f}}$	$\text{CuSiO}_2^{\text{h}}$	AgNO_3	CuSO_4
Bacteria	<i>E. coli</i>	1000	10	1000	1	10
	<i>P. putida</i>	1000	10	>1000	1	10
	<i>A. globiformis</i>	1000	10	>1000	10	10
Yeast	<i>S. cerevisiae</i>	>1000	1000	>1000	10	100
	<i>C. arborea</i>	>1000	1000	>1000	100	1000
	<i>C. albicans</i>	>1000	1000	>1000	100	1000
Fungi	<i>A. niger</i>	>1000	1000	>1000	100	>1000
	<i>A. terreus</i>	>1000	10	>1000	1	>1000
	<i>S. brevicaulis</i>	>1000	1000	>1000	1000	1000



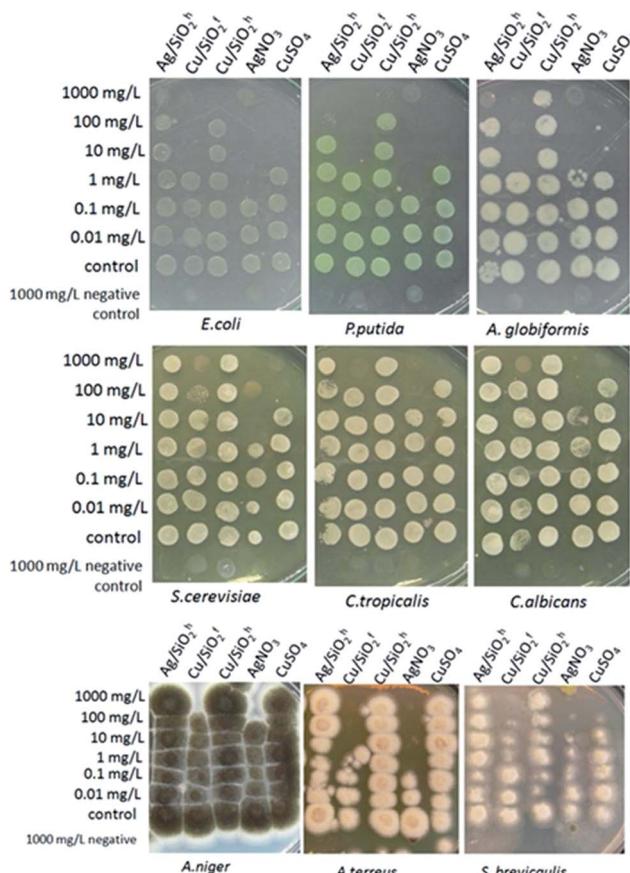


Fig. 8 Colony-forming ability of bacteria, yeast and fungi after 24 h exposure to Ag/SiO_2^h , Cu/SiO_2^f (hydrophilic), Cu/SiO_2^h (hydrophobic), Ag- and Cu-ions in deionized water at 24°C . After exposure, cells ($5\ \mu\text{L}$) were transferred onto toxicant-free agarized growth medium.

380, 466, cm^{-1} assigned to the Cu–O vibration⁷³ and other ones with lower intensity to the (Si–O)–Cu modes.

Antimicrobial properties of nanocomposites. In order to evaluate the antimicrobial potential of the silver- and copper-silica nanocomposites as well as metal ions used as reference

of tested nanomaterials, the ‘spot test’ experiment have been performed (see Fig. 8 and Table 4). We have simulated a potential exposition as it can be expected in the natural poor nutrient environmental conditions by incubating the analyzed microbial strains in deionized water.³⁷ In this test, the toxic effect was not modulated by different growth media, although it allows for the analysis of metallic compounds, which typically showed tendency to form non-bioavailable complexes with ligands in media.

The highest antibacterial effect was observed for hydrophilic Cu/SiO_2^f , for which minimum biocidal concentration (MBC) was determined at the level of $10\ \text{mg L}^{-1}$ after 24 h (Table 4). The same level of antibacterial properties showed Cu-ions (CuSO_4), although it should be considered that content of Cu in synthesized nanocomposites was 2.48% and 11.77% for hydrophobic and hydrophilic systems (based on the SEM + EDX analysis), respectively.

Antifungal properties of copper are used especially in agricultural management where copper consists is an active substance of inorganic fungicides.⁷⁴ Moreover, antifungal activity of Cu NPs may be higher than for commonly used fungicide in bulk.⁷⁵ Hence, to shed more light on the toxic effect of the silica-based nanocomposite, more detailed studies against fungal strains of all systems were carried out. The outcomes showed the Cu/SiO_2^f composite demonstrated higher toxic effect than Cu-ions. For *A. terreus* the toxic effect calculated for Cu/SiO_2^f was more than 100 times higher in comparison with Cu-ions. In contrast, the weakest biocidal effect was observed for Cu/SiO_2^h nanosystem. This effect might be connected to certain nanoparticles properties such as size or degree of metal agglomeration.⁷⁶ In our study the particle size of hydrophobic Cu/SiO_2 was about 3 times bigger compared to the hydrophilic Cu/SiO_2 nanocomposite. Moreover, Cu concentration in hydrophobic silica matrix was almost 5 times smaller than hydrophilic one.

Further, the Ag/SiO_2 nanocomposite was determined. However, no toxic effect on the yeast or fungi strains was found. The comparison of MBC values of the Ag and Cu combined with

Table 5 Inhibitory concentration (IC_{50}) of nanocomposites and combined with IC_{50} of Ag- and Cu-ions for bacterial strain (mg L^{-1})^a

Bacterial strain	Ag/SiO_2^h	Cu/SiO_2^f	Cu/SiO_2^h	AgNO_3	CuSO_4
<i>E. coli</i>	96.1 ± 6.1	81.9 ± 9.9	78.4 ± 7.2	8.0 ± 1.3	555.2 ± 8.9
<i>P. putida</i>	1091.5 ± 112.9	96.2 ± 8.8	>1000	5.1 ± 0.1	512.3 ± 5.7
<i>A. globiformis</i>	>1000	55.0 ± 3.5	>1000	5.9 ± 0.2	564.8 ± 14.1

$\text{Range of } \text{IC}_{50}:$	$1\text{--}9.9\ \text{mg L}^{-1}$	$10\text{--}99\ \text{mg L}^{-1}$	$100\text{--}1000\ \text{mg L}^{-1}$	$>1000\ \text{mg L}^{-1}$
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^a Range of IC_{50} :

Table 6 Inhibitory concentration (IC_{50}) of nanocomposites and Ag- and Cu-ions for cell cultures ($mg\ L^{-1}$)

Cell culture	Ag/SiO_2^h	Cu/SiO_2^f	Cu/SiO_2^h
NHDF	>100	>50	>40
^a Range of the tested concentrations	100–25	50–25	40–10

^a Solubility depending.

hydrophobic SiO_2 showed higher antibacterial effect of nano-materials contained silver. Similar results have been published by Suppi *et al.*,³⁷ where smaller biocidal effect of Cu NPs in comparison with AgNPs was found.

Inhibitory concentration IC_{50} test performed on selective bacterial strains revealed lower antibacterial potency compared to the results obtained by 'spot test' (see Table 5). It may indicate that observed toxic effect results not from the disruption of the active growth of bacterial strains, but has general nature. It has been considered, that Cu- or Ag-based NPs are highly reactive due to their large specific surface area to the bulk one, which may be responsible for inducing generation of the reactive oxygen species. It may affect microorganisms by disruption of cell wall, lipid peroxidation or damage of DNA/RNA.⁷⁷

Similarly, to the results obtained by 'spot test' for all tested nanocomposites, the Cu/SiO_2^f exerted the highest toxic effect against bacteria and the effect was higher in comparison with Cu-ions. Moreover, all NCs exert toxic effect on gram-negative bacteria *E. coli*. Toxicity of NPs against bacterial strain was examined also in other studies.^{78,79} It was shown, that silver ions may be released from the surface of Ag/SiO_2 coating films and exerted totally inhibited growth effect on *E. coli* in comparison with *S. aureus* (90% bactericides), due to trapping silver ion by peptidoglycan in the gram-positive cell wall.⁷⁸ This effect is similar to our results, where gram-positive strain of *A. globiformis* showed a lower sensitivity to tested compound compared to *E. coli*. Additionally, capping of nanoparticles by

exopolysaccharides produced by bacteria may be responsible for tolerance of bacteria for AgNPs.⁷⁹ This may explain small inhibitory effect of nanomaterials against strain of *P. putida* G7, which is known as producer of exopolymers.⁸⁰

Cell culture and cytotoxicity assay. Inhibitory concentration test performed relative to the human fibroblast cells was used to assess cell viability and cell proliferation. The outcomes have shown no significant signs of cytotoxicity in case of all tested nanocomposites (Table 6). It may suggest that similar metal concentrations ($mg\ L^{-1}$) like applied to the bactericidal tests ($IC_{50}\ mg\ L^{-1}$), does not exclude an active growth of human fibroblast in the solution (Fig. 9). Additionally, no differences in cytotoxicity suggest limitation of negative impact of nano-silver and nano-copper on the human cells.

Conclusions

This paper has summarized a complete process of production and characterization of metallic (silver, copper) silica-based powder nanocomposites with the use of hydrophilic and hydrophobic silica matrices. Diffraction data revealed presence of amorphous and crystalline silica phases while chemical analysis, heterogeneously distribution of metallic ions and carbon within silica matrix as well as their potential agglomeration in submicron clusters. Microscopy images revealed round-shape morphology of metallic ions as well as evidenced an average size of silver and copper embedded into hydrophobic matrix close to 12 nm, while in case of hydrophilic ones close to 4 nm. Surface sensitive methods indicated the presence of silver and copper oxides, surface adsorbed carbon and stoichiometry and non-stoichiometric silica phases. Infrared and Raman spectroscopy showed presence of major silica-active bands as well as metallic-oxide bonds. Biological test revealed antibacterial and antifungal properties of synthesized nanocomposites, in some cases even better than those reported for silver- or copper-based, commonly used chemical compounds. Significantly, the highest biocidal properties were determined for nanocomposite with smallest particle size and proved the lack of cytotoxic effect of all nanocomposites for the human cells.

Acknowledgements

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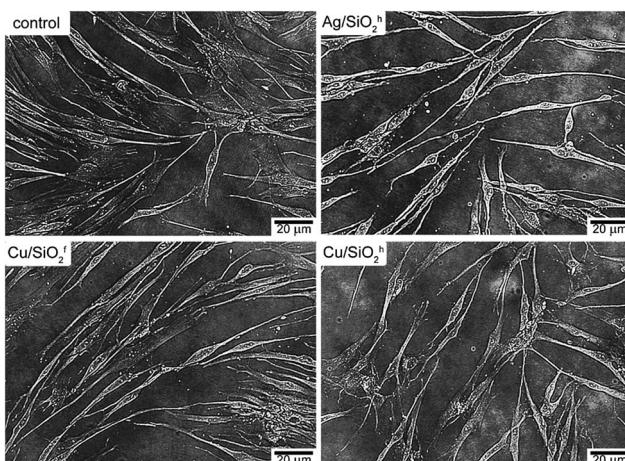


Fig. 9 The cell morphology of NHDF after a 72 h treatment with control, Ag/SiO_2^h , Cu/SiO_2^f , and Cu/SiO_2^h .



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